

ASSIGNMENT BPT 401

— Krista sir

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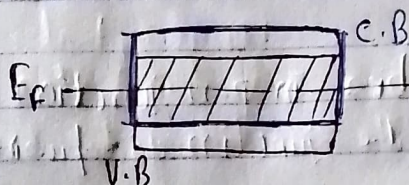
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1) What is the difference between the band gap formation in metal, semi-metal & semi-conductor.

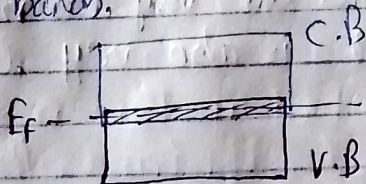
In metals:-

- Conduction band & valence band overlap each other leaving zero band gap between them.
- In metal, fermi level have large space/amount for conduction & valence band overlapping.



In Semi-metals:-

- There is a very little overlapping between conduction band & valence band & hence zero band gap.
- fermi level has very less amount of overlapping of bands.



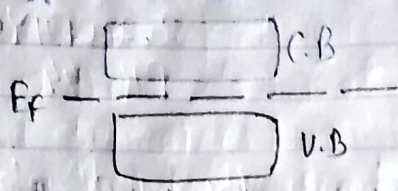
In Semi-conductors:-

- There is a very little band gap exist in semiconductors (no overlapping).
- ↳ It is the minimum energy required to make conduction.

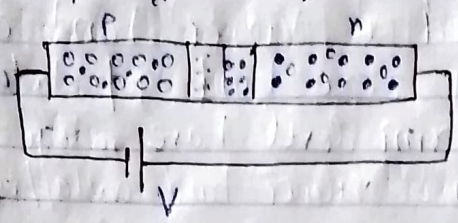
→ Fermi level lies in the semiconductor in the middle of semiconductor depending upon its types.

1)

For eq 1 \rightarrow for intrinsic semiconductor $\rightarrow E_F$ lies exactly in middle of bands



2) Why do we have conduction in the reverse bias condⁿ of a p-n junction?



In case of reverse bias in p-n junction, majority carriers cannot cross the junction as repulsive force increases.

As reverse bias voltage increased, energy bands on p-side are raised up.

While for minority charge carrier this p-n junction in reverse bias behaves as forward bias & since minority charge carrier are very less no. so, the current minority carriers is also very less or is negligible.

3) Why the Fermi level posⁿ change in the band gap as we alter the doping level in the semiconductor materials?

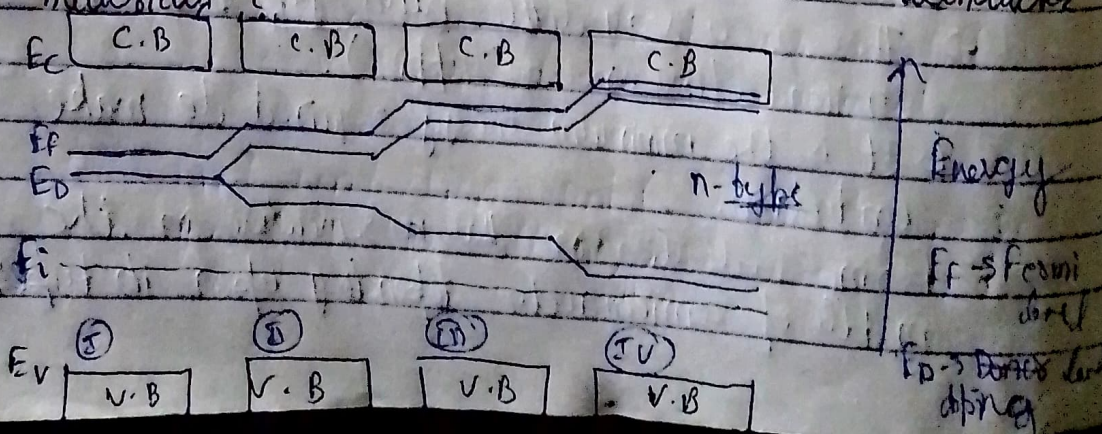


Fig I \rightarrow low doping

Fig II \rightarrow high doping

Fig III \rightarrow Med^m "

Fig IV \rightarrow extremely high doping

3) Fig

For n-type Semiconductor

As doping concⁿ increases, i.e. more number of penta-valent atoms doped, so more number of electrons are available in donor will be available. As a result, centre of mass of electrons gravity position of electrons shifted upwards.

So, Fermi level shift towards conduction band.

For

~~Fig~~ \rightarrow In Fig. IV E_F is inside C.B. represents extremely high doping.

For p-type semiconductor

Similarly, as in n-type semiconductor, here holes concentration increases due to trivalent impurity.

So, Fermi level shift towards valence bands.

4) What is the difference between Zener Diode & Avalanche breakdown in a p-n junction?

4) Zener Diode

Avalanche Breakdown

\rightarrow Only happens when doping concⁿ is extremely high.

So, the depletion region become very narrow.

\rightarrow Electric field is very strong & extremely narrow. So, charge carrier can't get accelerated. Instead a quantum mechanical effect takes place.

\rightarrow Due to Avalanche effect

\rightarrow If reverse bias voltage is very high, then the depletion region widens, & the electric field is quite strong.

\rightarrow Minority carrier get accelerated in this depletion region & gain K.E.

4)

1) This is like quantum tunneling.

So, there is no impact ionization, the electron just tunnel through (like digging a hole, instead of overcoming the mountain).

2) So most e^- tunnel through, & some of course will give impact ionization.

→ Once the field is strong enough, they can knock off other e^- from the tree in the depletion region.

3) This e^- can in turn can knock off other e^- from ions in depletion region. So, large no. of e^- are available for conduction.

4) However, due to impact ionization, heat is generated & this heat could destroy the diode.

5) Why there is no conduction of charges in the lower value of the applied forward bias condition in the p-n junction?

initially

In forward biasing of p-n junction diode, due to the high depletion width no electron can cross the barrier & hence no conduction.

As forward bias voltage increases, electron & holes are pushed by battery from n-side & p-side respectively. As a result, depletion width decreases.

Although the depletion width is decreasing, still no. of electrons crossing the barrier is still very less, i.e. we get negligible or zero current.

We don't conduction until forward bias voltage is equal to barrier voltage, then the energy bands

on two sides are aligned & majority carriers can cross the junction.

And when, majority carriers can easily cross the junction, we get conduction until the we get negligible no conduction.

THE  END